

AMENDMENTS TO THE SPECIFICATION

Kindly amend the “Brief Description of the Drawings” section of the application papers by adding the following after paragraph 0046 of the published application papers as indicated below:

[0046] Figure 25 is a graphical illustration of 2-point resistance measurements as a function of applied voltage of the three embodiments of Figure 24.

Figure 26 is a sectional illustration of another SRAM wafer according to the present invention.

Figure 27 is a graphical illustration of the resistance behavior of embodiments of the present invention.

Figure 28 is a graphical illustration of the resistance behavior of Si local resistor films according to the present invention.